

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	23	(438/639.ccls. 438/761.ccls. 438/763.ccls. 438/791.ccls. 438/792.ccls.) and ((bitline (bit adj line)) with nitride with (spacer hardmask (hard adj mask) sidewall (side adj wall)))	US-PGPUB; USPAT	OR	ON	2005/02/04 14:11
L2	124	((bitline (bit adj line)) with nitride with (spacer hardmask (hard adj mask) sidewall (side adj wall))) and ((high adj density adj plasma) hdp cvd (hdp adj cvd))	US-PGPUB; USPAT	OR	ON	2005/02/04 14:25
L3	128	((bitline (bit adj line)) with nitride with (spacer hardmask (hard adj mask) sidewall (side adj wall))) and (contact hole opening via plug landing land)	EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/04 15:05
L4	1	2004-560537.NRAN.	DERWENT	OR	OFF	2005/02/04 15:11
L5	381	((bitline (bit adj line)) with nitride with (spacer hardmask (hard adj mask) sidewall (side adj wall))) same ((contact hole opening via plug landing land) with (ild interlayer insulat\$6 dielectric organic (silicon adj (oxide dioxide))))	US-PGPUB; USPAT	OR	ON	2005/02/04 15:17
L6	2235	438/639.ccls. 438/761.ccls. 438/763.ccls. 438/791.ccls. 438/792.ccls.	US-PGPUB; USPAT	OR	OFF	2005/02/04 15:41